

MOCVD Routes to 2D Crystals

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2D at Penn State

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Zhiwen Liu	Sulin Zhang
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Director



Mauricio Terrones



Students/Post-docs

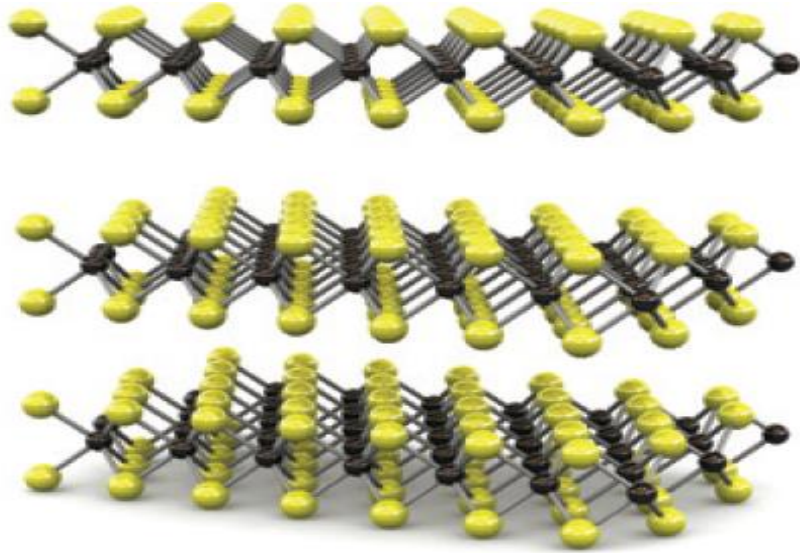
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Amin Azizi	Lavish Pabbi
Zakaria Al Balushi	Nestor Perea
Ganesh Bhimanapati	Lakshmy Rajukumar
Donna D. Deng	Chris Rotella
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Robert Fraleigh	Junjie Wang
Jarod Gagnon	Yuanxi Wang
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Nina Kovtyukhova	Xiaotian Zhang
Chia-Hui (Candace) Lee	Liang Zhao
Yu-Chuan Lin	Rui Zhao
	Chanjing Zhou
	Zhong Lin
	Debangshu Mukherjee
	Roger Walker
	Shruti Subramanian

Assoc. Director



Joshua Robinson

Layered Materials

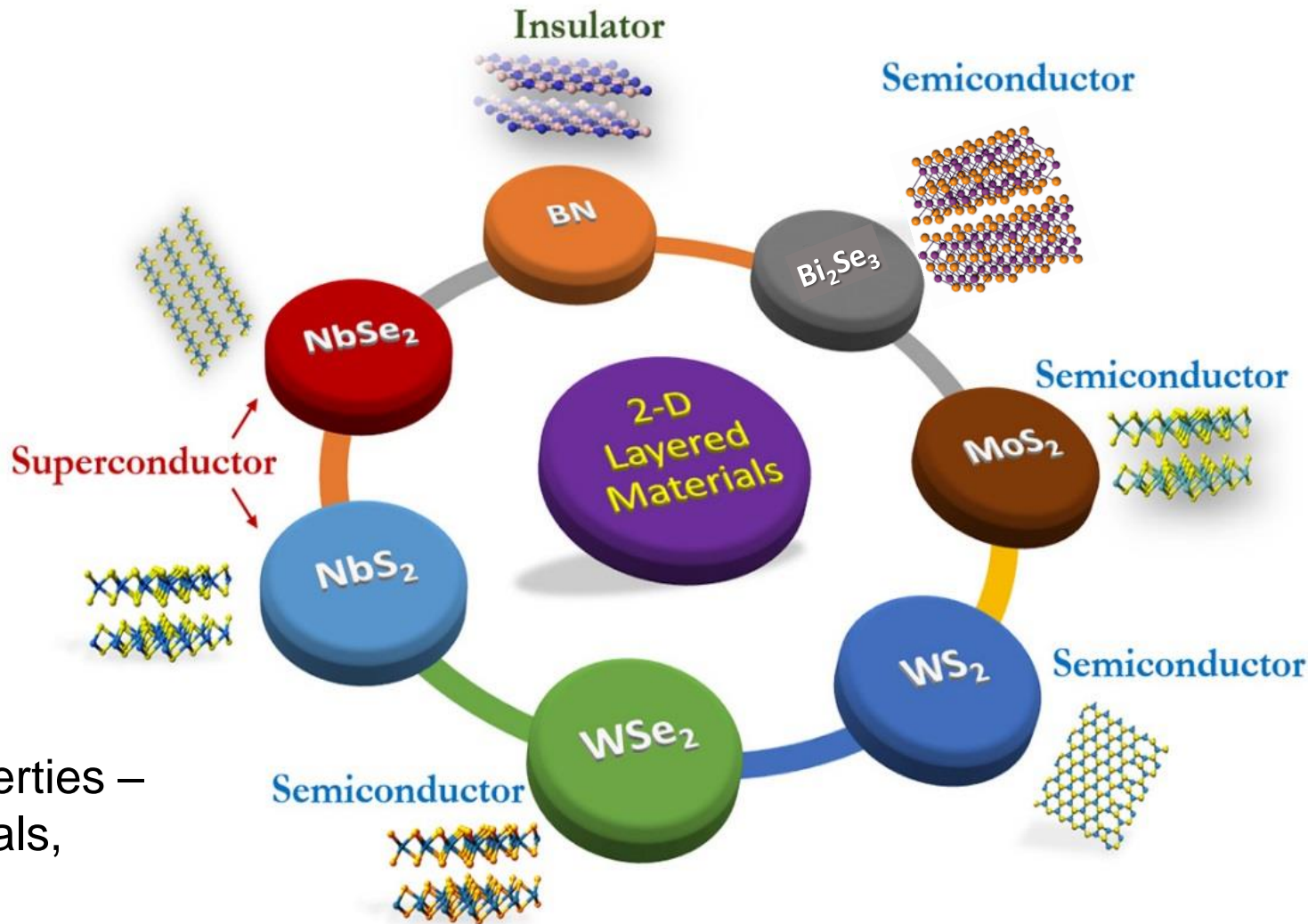


● X
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Superconductor

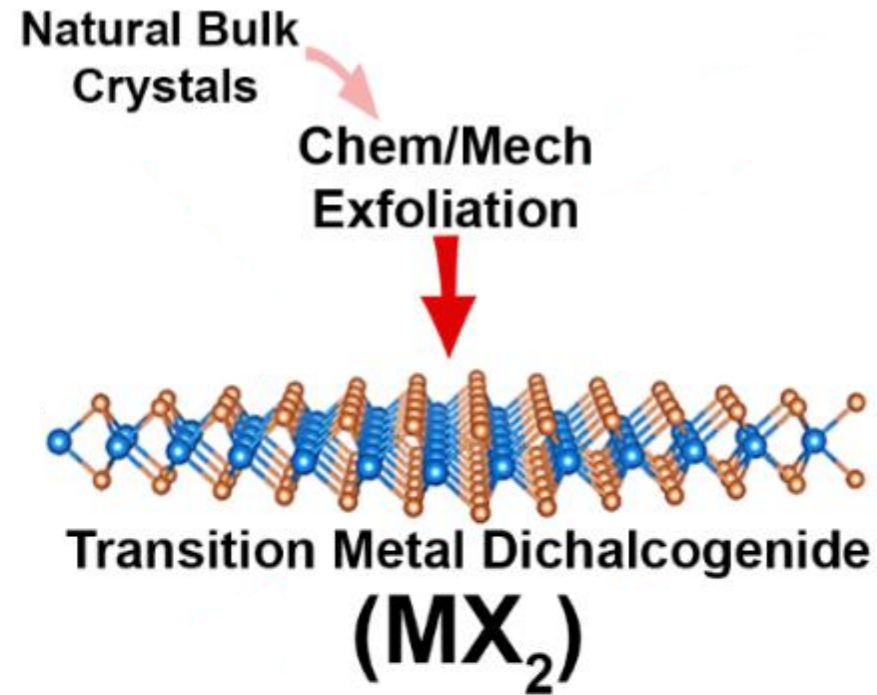
Q.H. Huang, et al.
Nature Nanotech. 7 (2012) p. 699

- Graphene-like layered materials
- Exhibit wide variety of electronic properties – insulators, semiconductors, semi-metals, superconductors



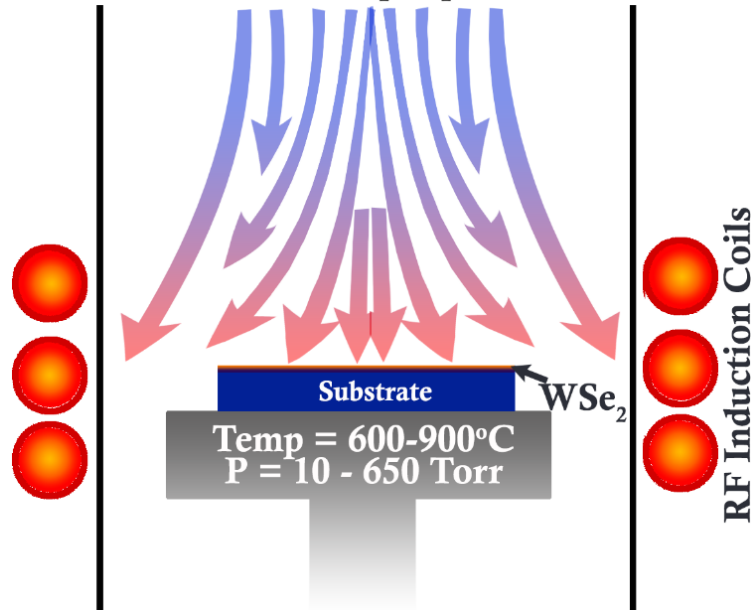
The TMD Synthesis “Atlas”

S. Das, J.A. Robinson, M. Terrones, et al.
Annual Review of Materials Research, 45, 1-27 (2015)

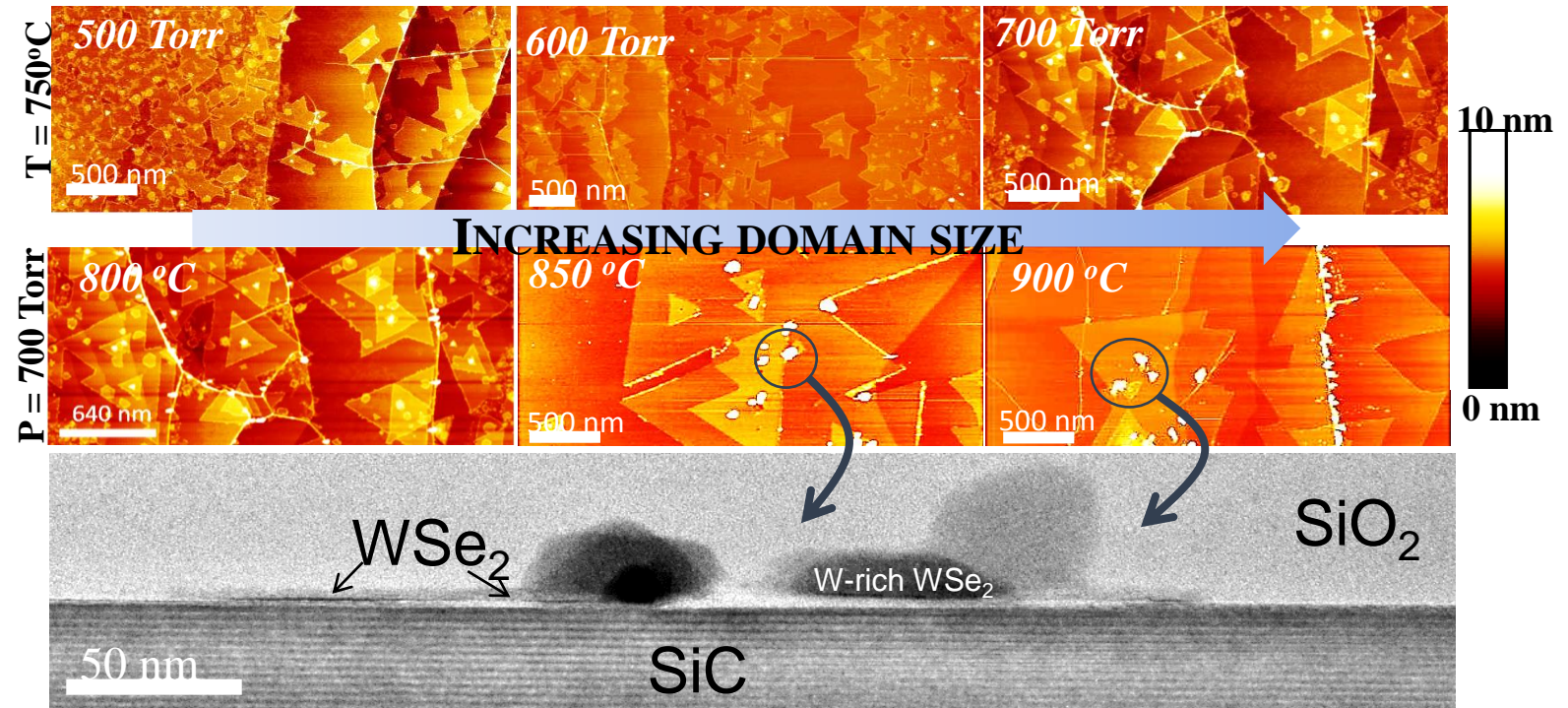
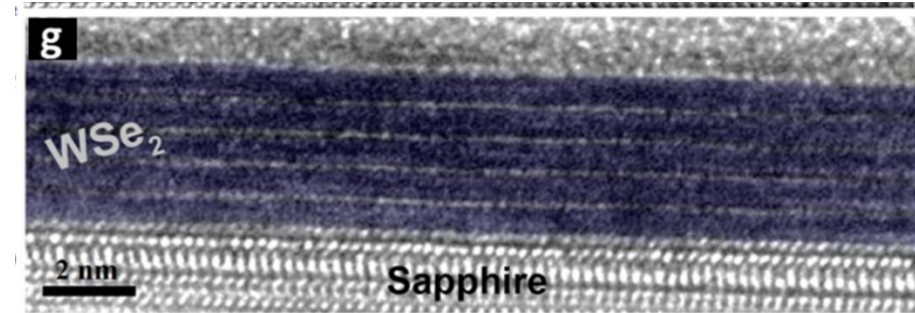


Metalorganic Chemical Vapor Deposition

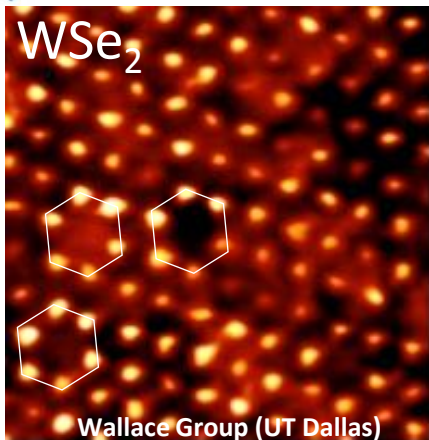
Metal Precursor: $\text{W}(\text{CO})_6$
Se Precursor: $(\text{CH}_3)_2\text{Se}$
Carrier: $\text{H}_2/\text{N}_2/\text{Ar}$



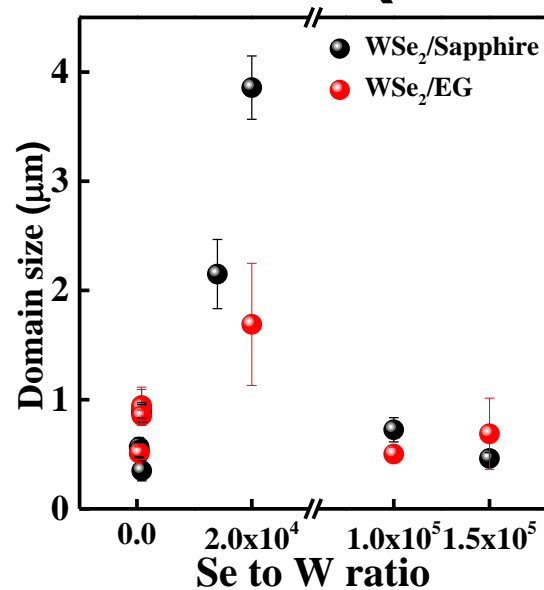
- Highly scalable process
- Excellent control over W:Se ratio



Tungsten Diselenide (WSe₂)

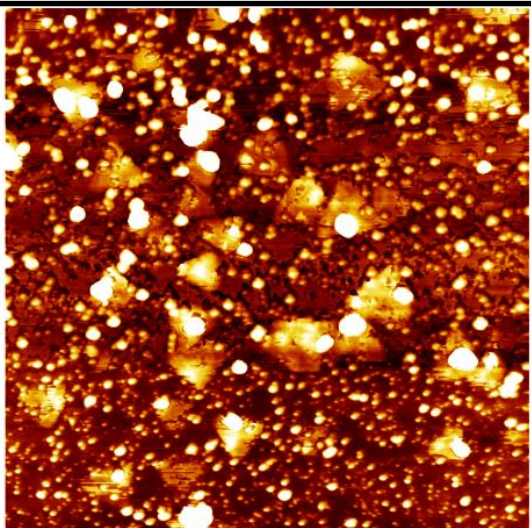


- Defects serve as nucleation sites in 2D materials.
- Typical defects are chalcogen (S, Se, Te) vacancies.

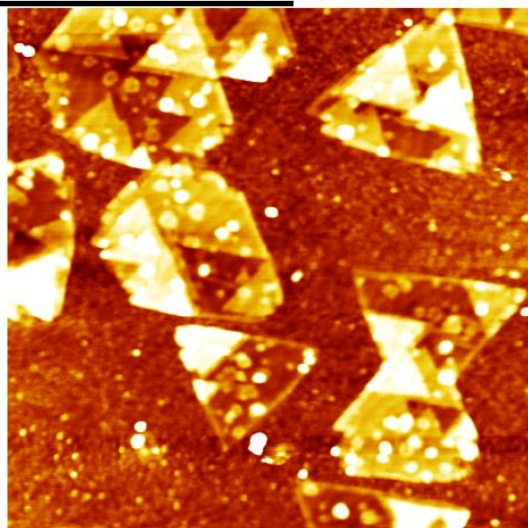


Se:W ratio has significant impact on domain size, shape, and “defect” formation

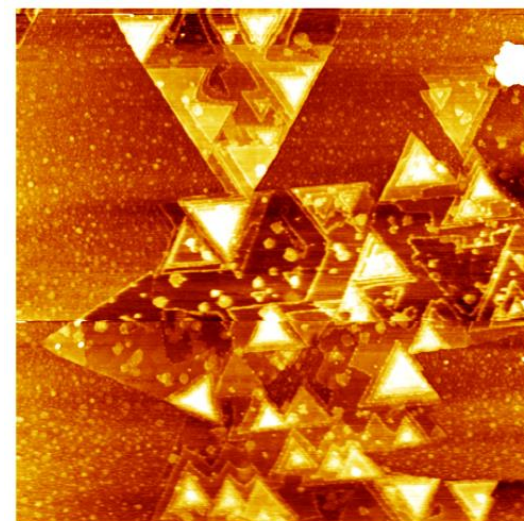
Temp (°C)	Time (min)	Pre- Anneal	Pressure (Torr)
800	30	500C, 15min	700



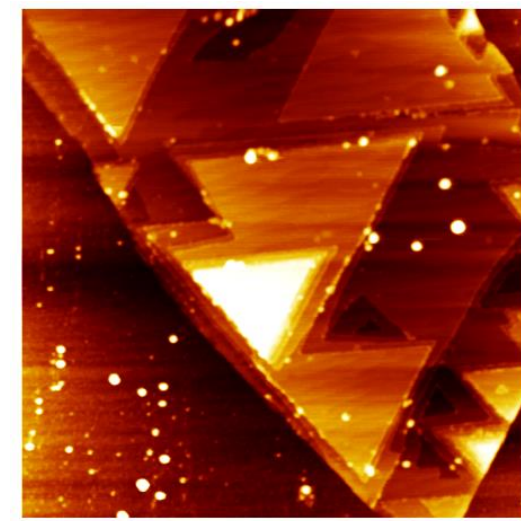
Height 400.0 nm
Se:W Ratio: 170



Height 400.0 nm
Se:W Ratio: 400

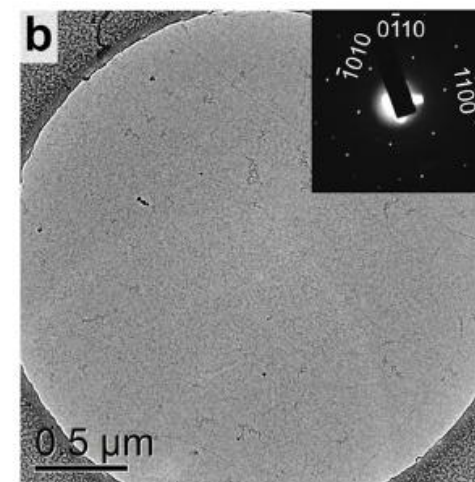
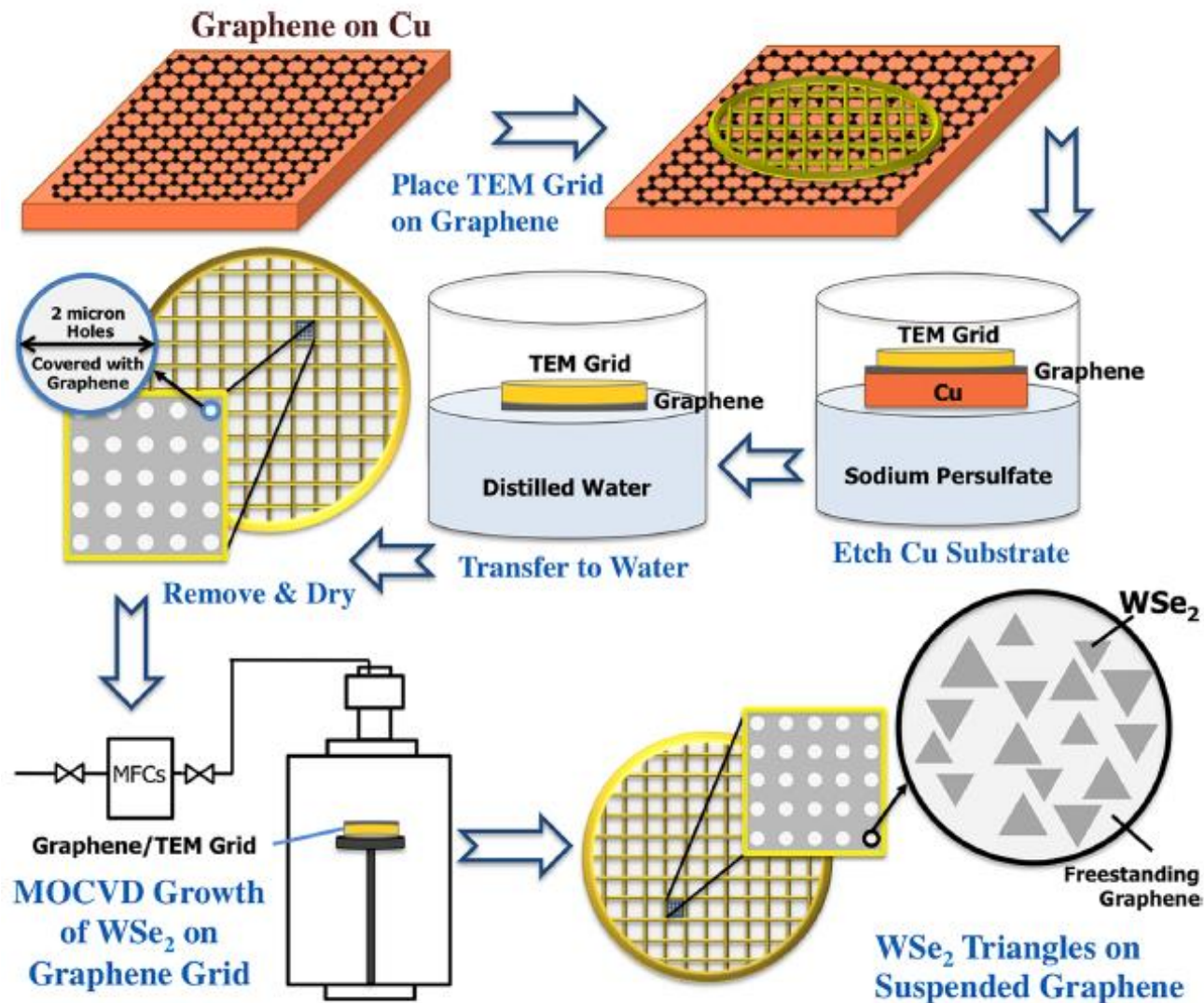


Height 400.0 nm
Se:W Ratio: 800

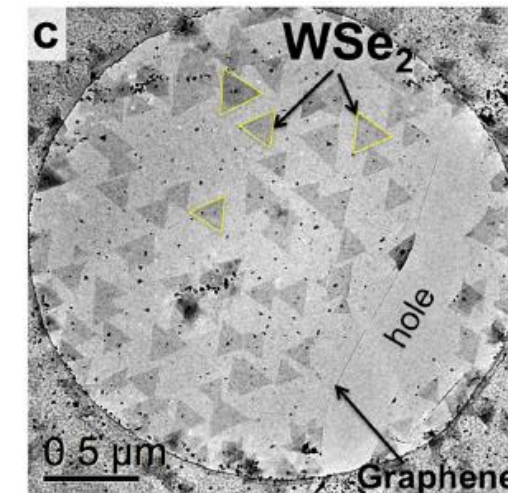


Height 400.0 nm
Se:W Ratio: 14000

WSe₂ on Free Standing Graphene Templates



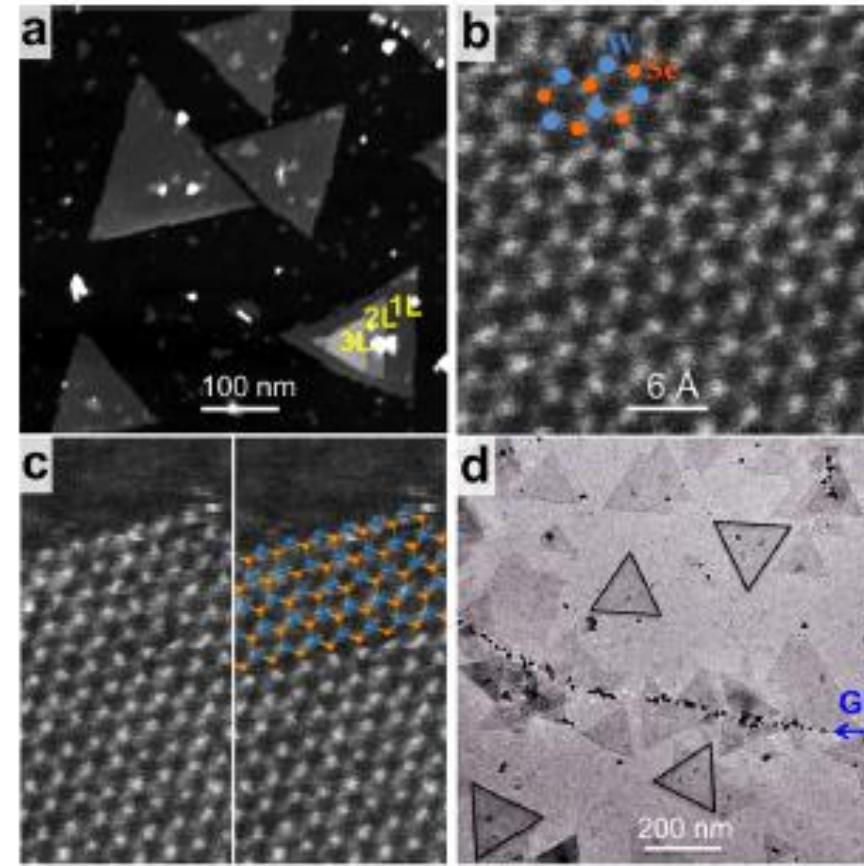
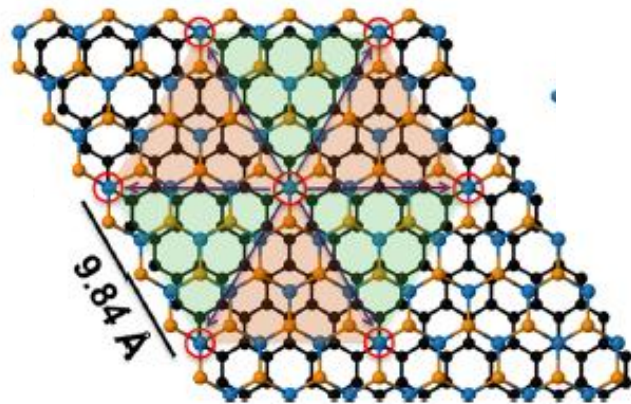
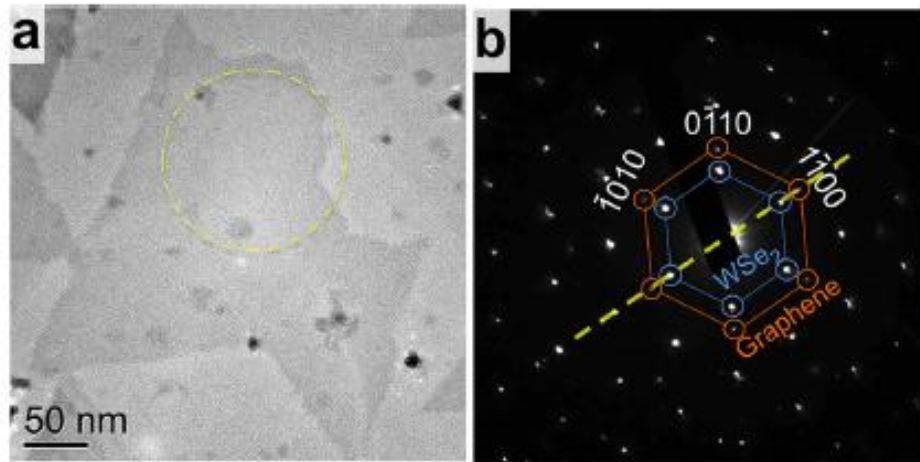
As Prepared



After MOCVD Growth

- Developed process to produce freestanding van der Waals heterostructures
- Ideal for investigating layer-layer interaction with graphene

WSe₂ – Epitaxy and Defects

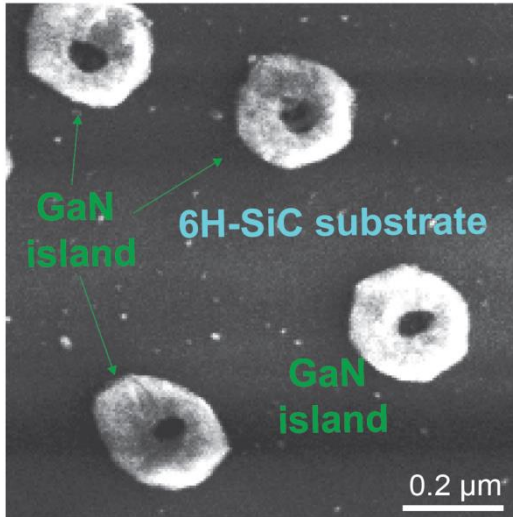


(a) TEM image and (b) SAD pattern showing epitaxial relationship between WSe₂ and graphene
(c) Structural model showing alignment of W atoms in WSe₂ and C atoms in graphene (circled in red)

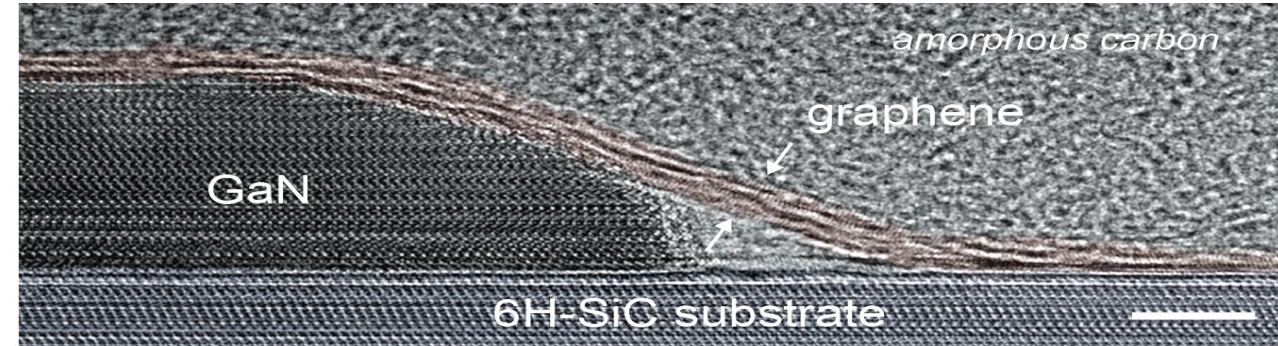
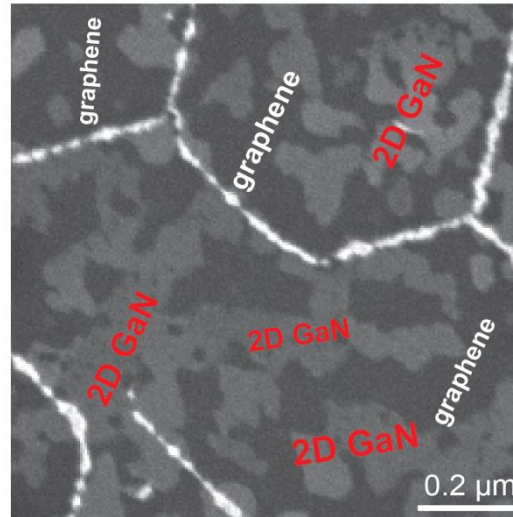
(a) HAADF-STEM image of monolayer and multilayer WSe₂
HAADF-STEM images of (b) monolayer WSe₂ and (c) edge region showing W-termination
d) TEM image showing nucleation near grain boundary in graphene

Pulsed MOCVD growth of GaN

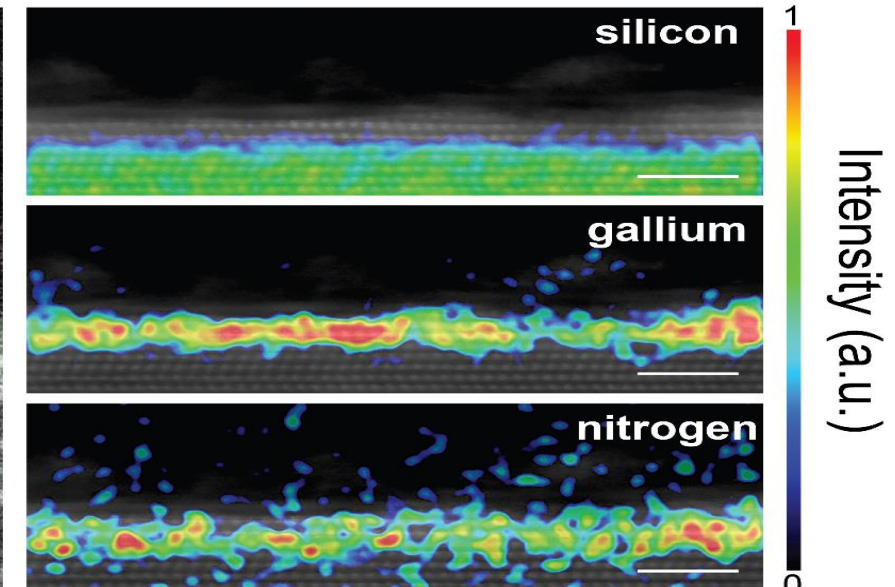
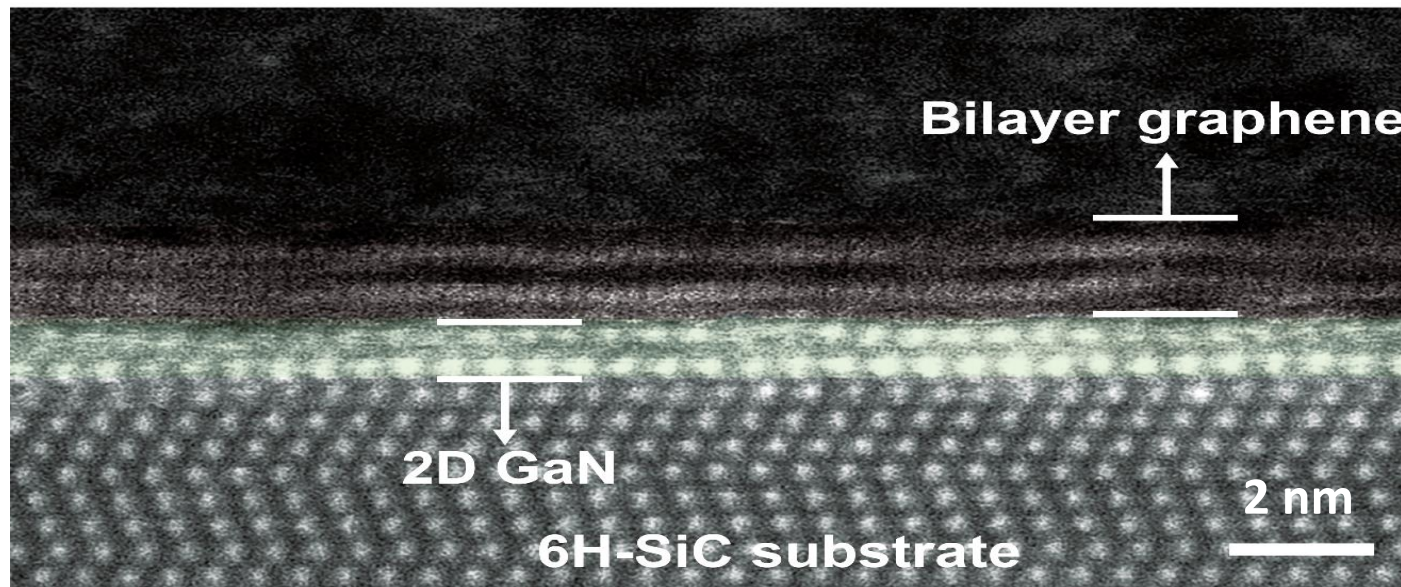
SiC Substrate



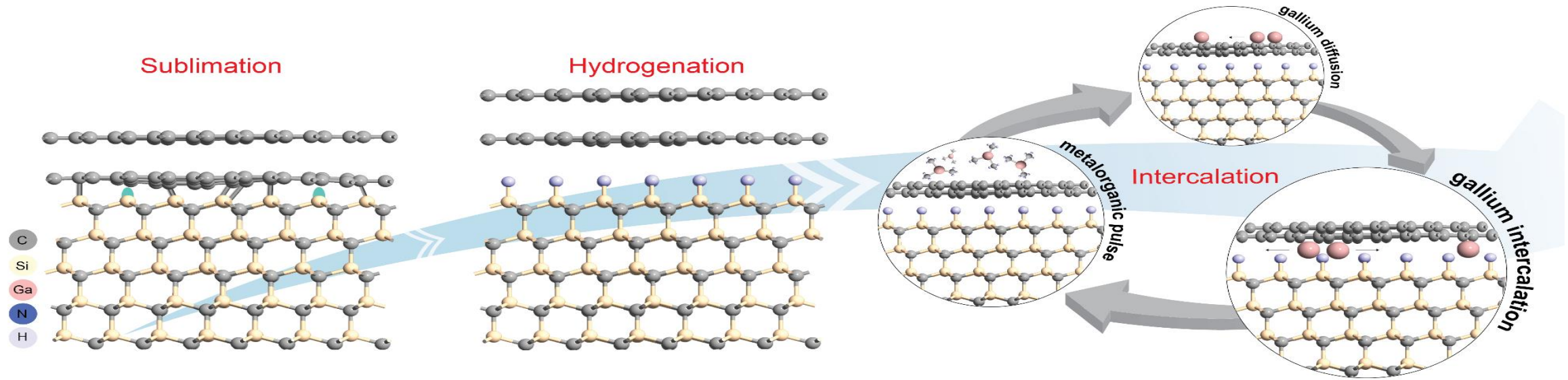
Epitaxial Graphene



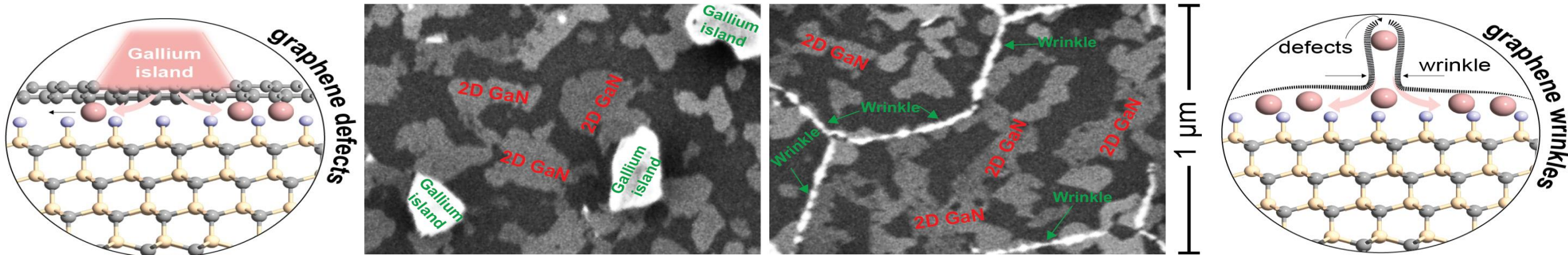
Cross-section TEM of GaN growing between graphene and SiC substrate



Ke Wang, PSU MCL

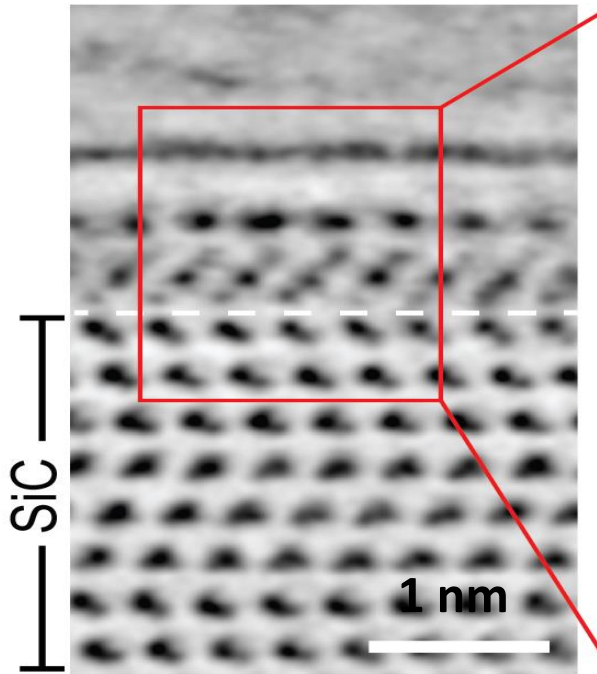


Pathways for Ga intercalation:

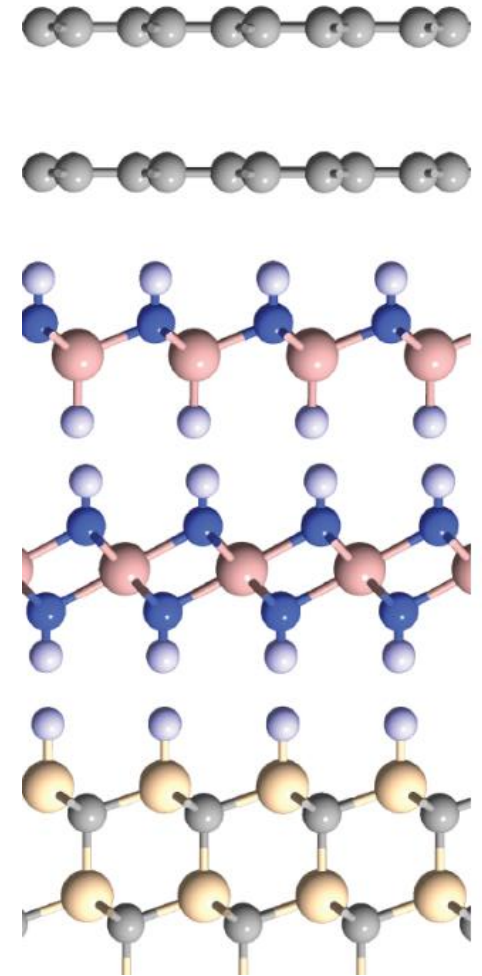
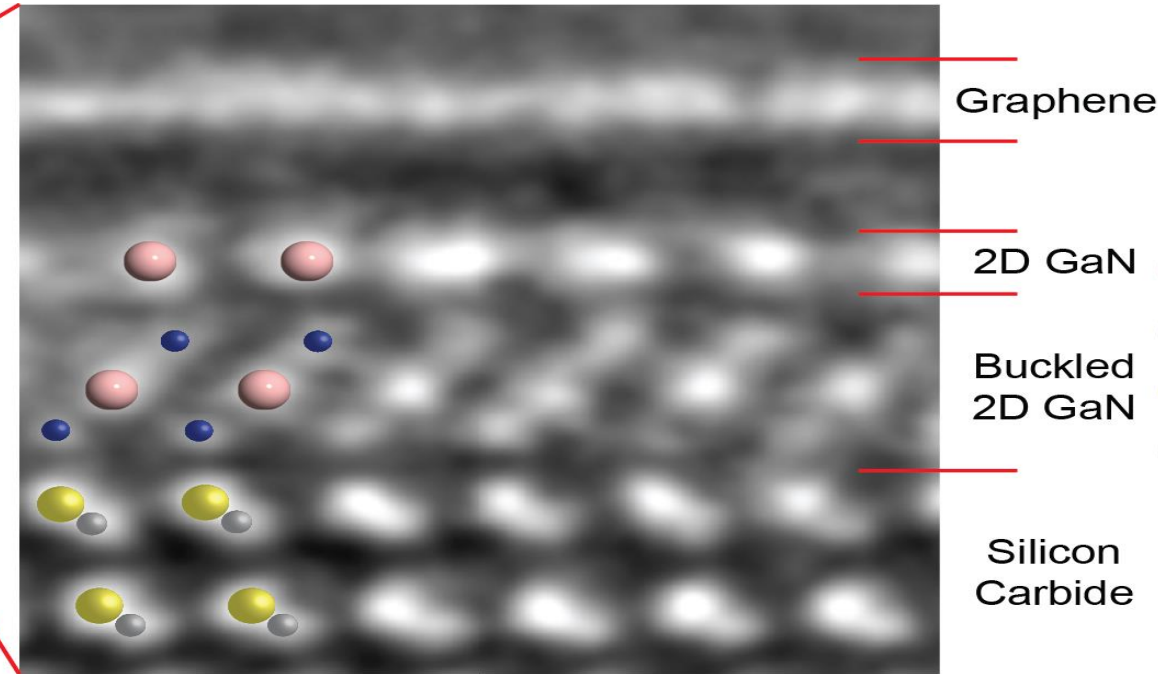


Atomic Structure of 2D GaN Layers

ABF STEM image near the $[11\bar{2}0]$ zone axis



Inverted image

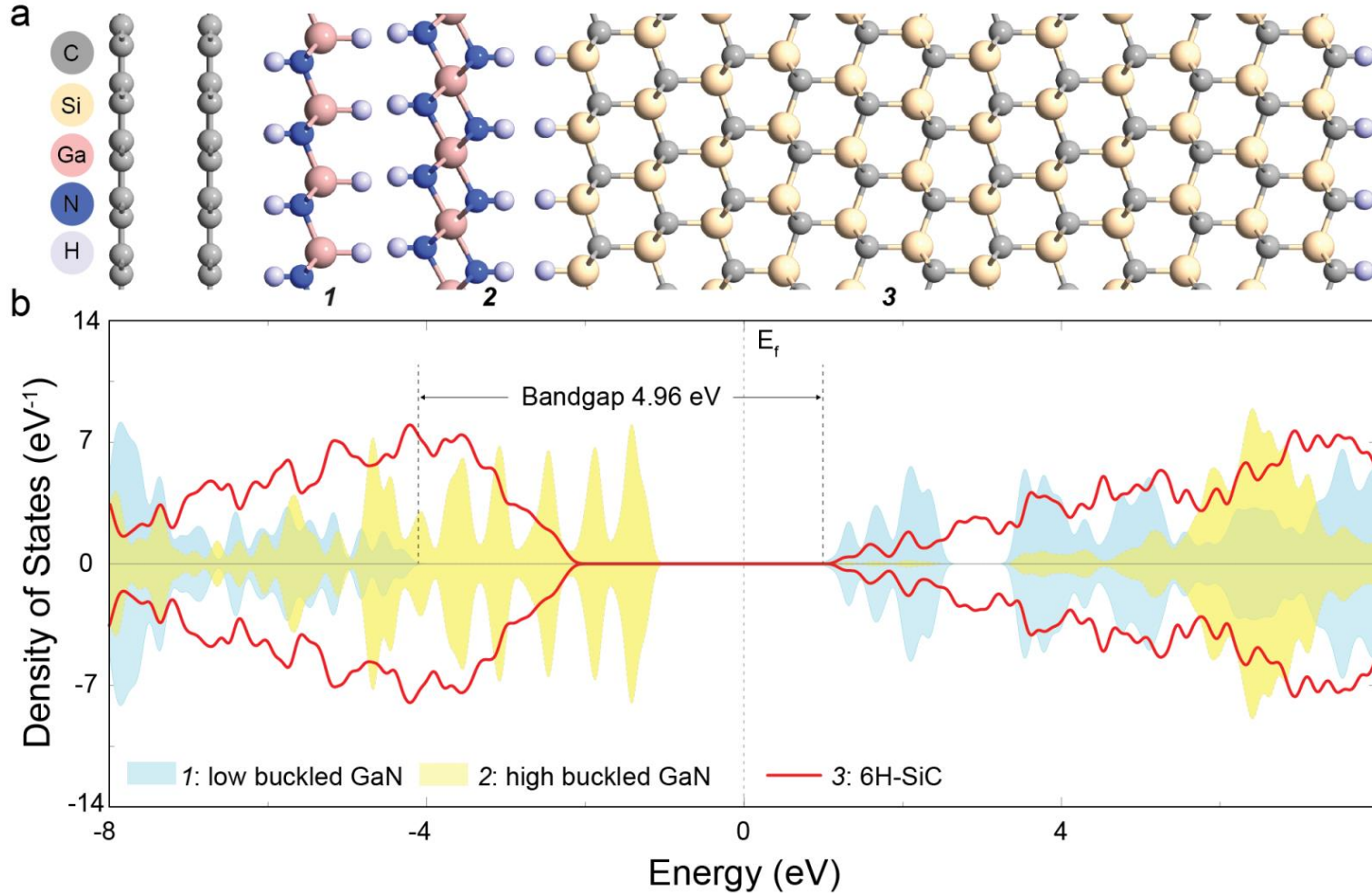


Two structurally different 2D layers of GaN at interface:

- Low buckled 2D GaN near graphene
- Highly buckled 2D GaN with nitrogen termination
- Only observed with graphene encapsulation

Ke Wang, PSU MCL

Electronic Structure of 2D GaN Layers



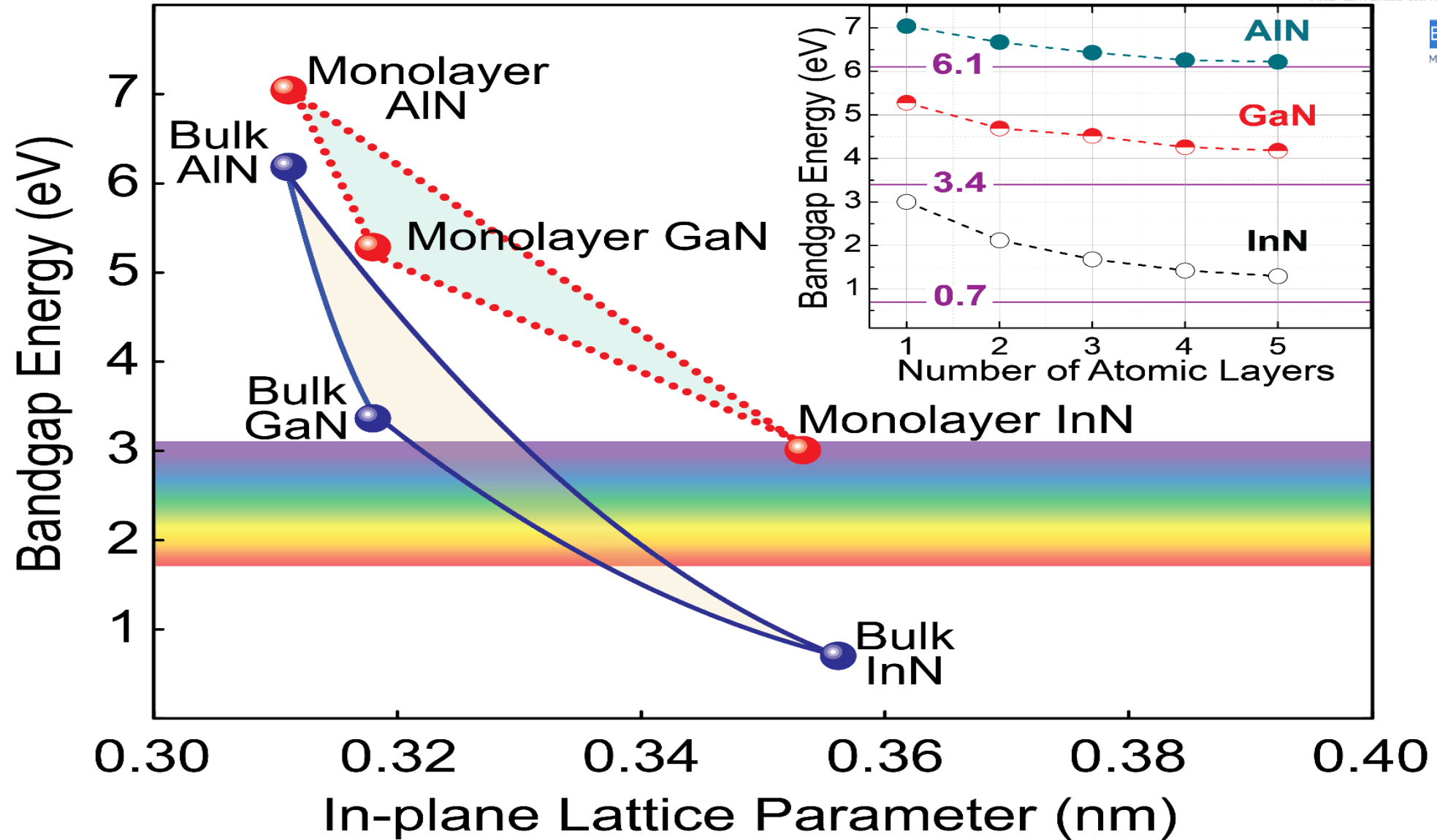
Predicted bandgap energies:

Low buckled GaN $E_g=4.96$ eV

High buckled GaN $E_g=4.24$ eV

Composite structure $E_g=2.02$ eV

Ram Krishna Ghosh and Suman Datta



Summary

- MOCVD is a promising technique for TMDs and layered materials
- Graphene encapsulated MOCVD growth viable method to stabilize 2D GaN
- Future work directed at heterostructure growth, alloys & doping

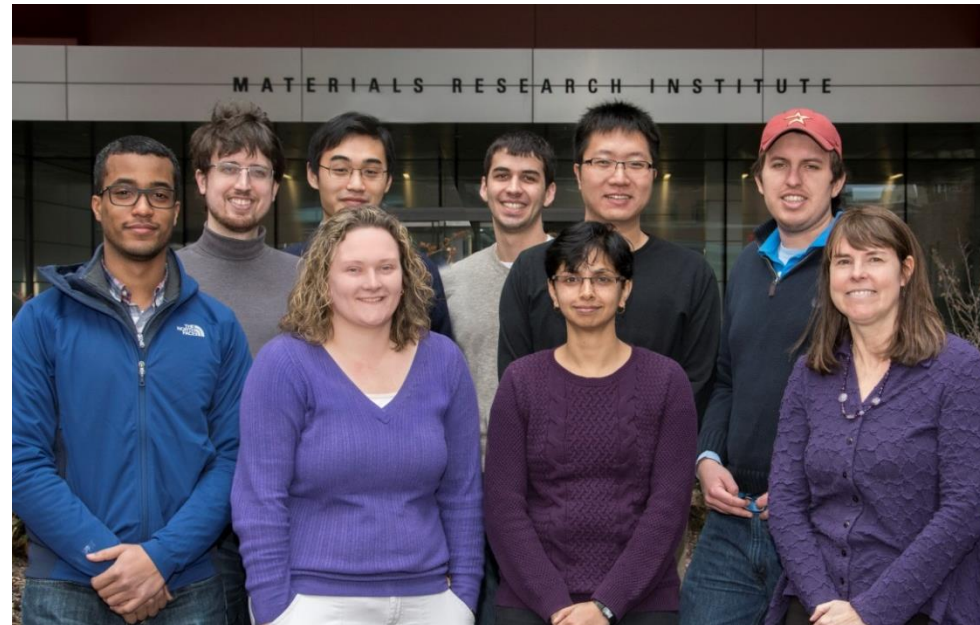
PSU Collaborators

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Dr. Josh Robinson (MatSE)
Dr. Nasim Alem (MatSE)
Dr. Suman Datta (EE)
Dr. Ke Wang (MRI)
Dr. Tom Jackson (EE)

Financial support provided by:



Acknowledgements

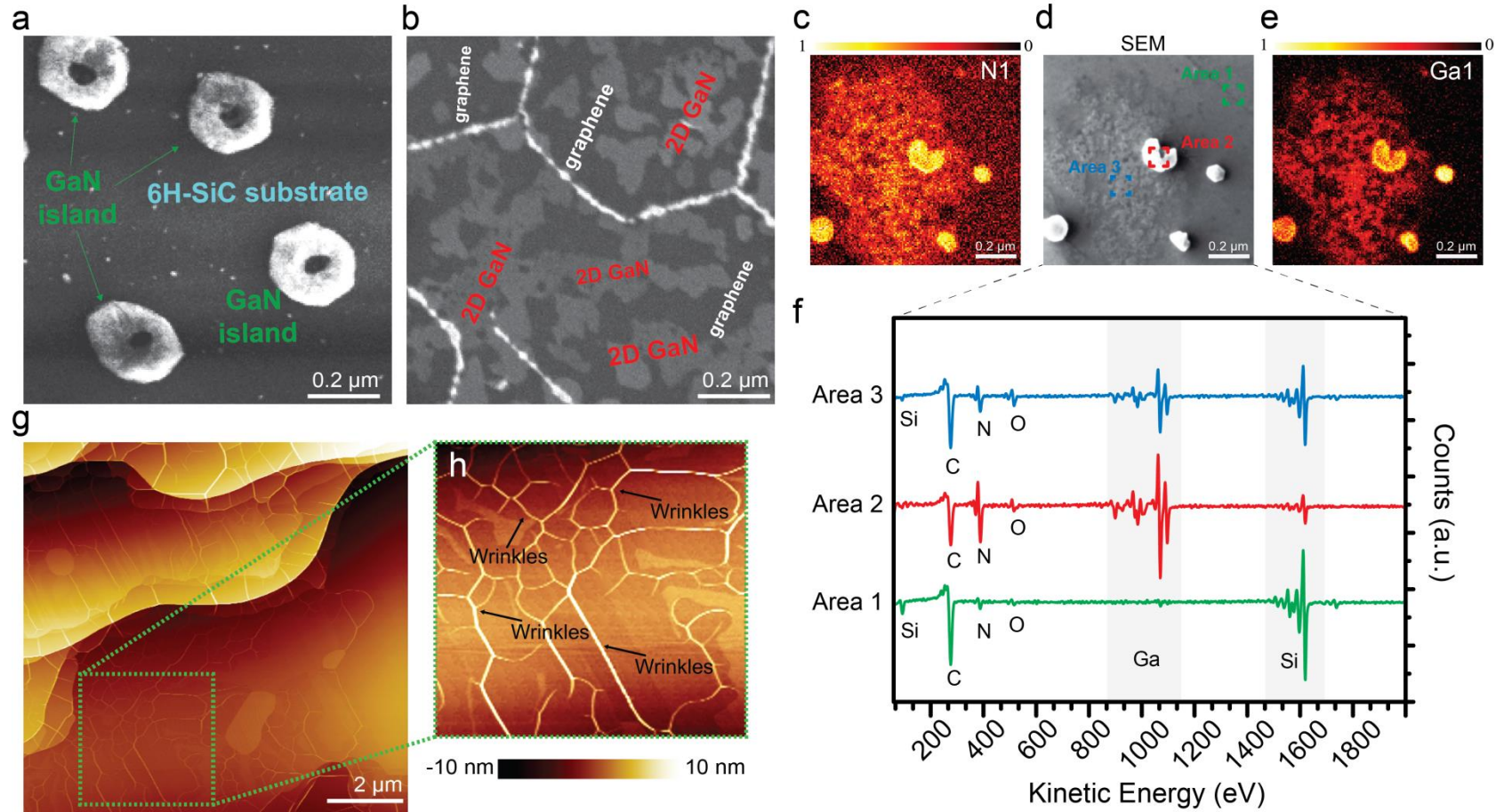


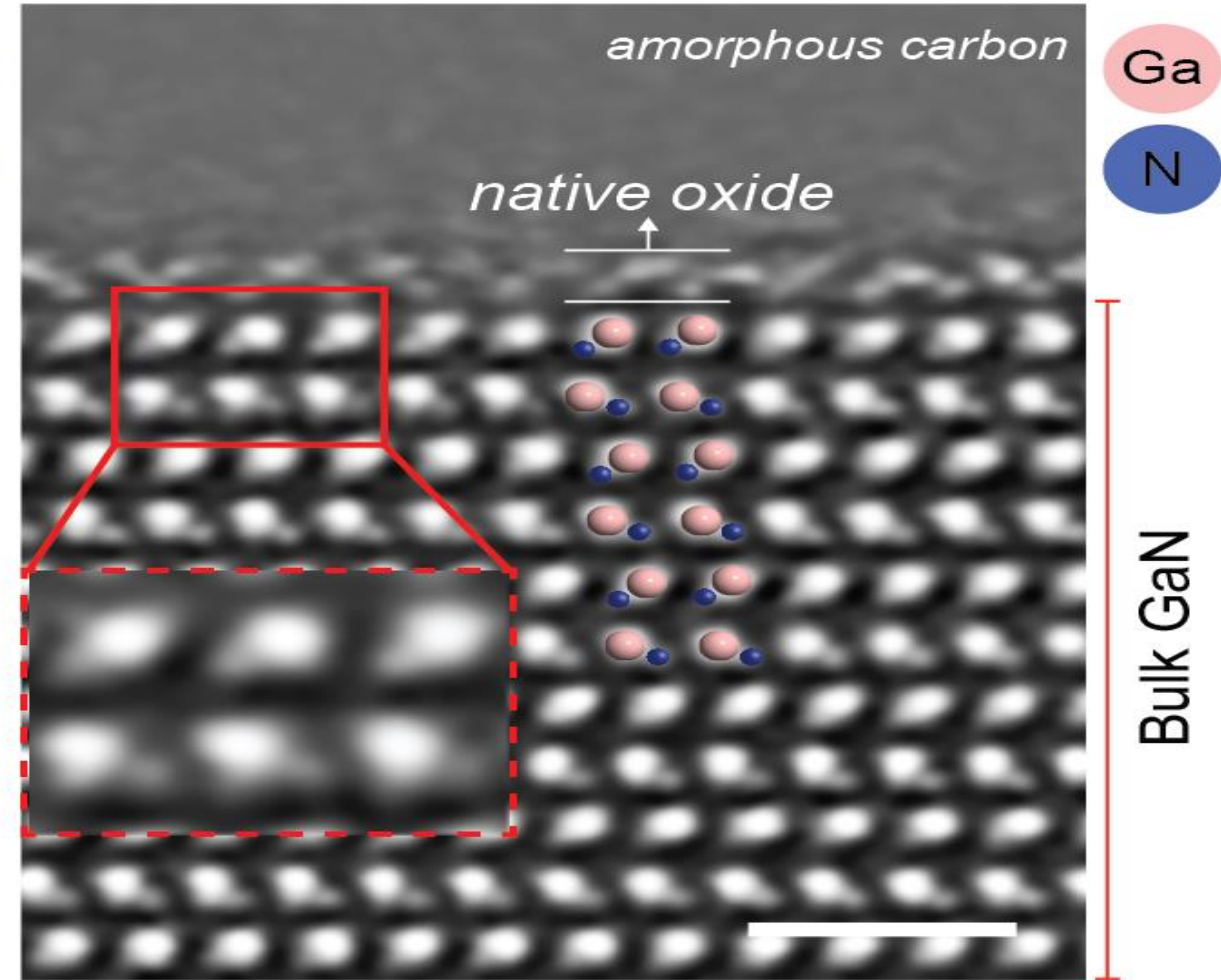
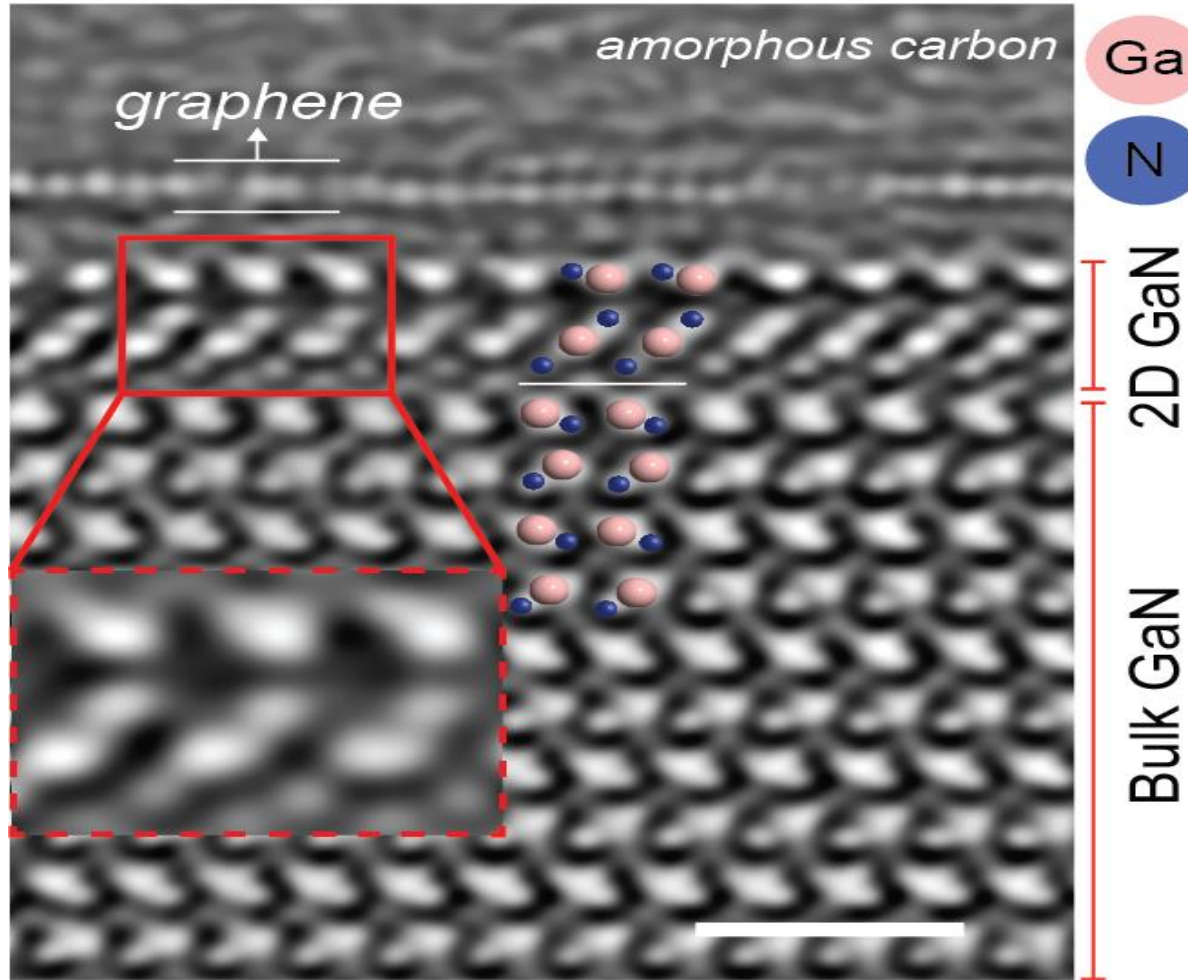
Graduate Students

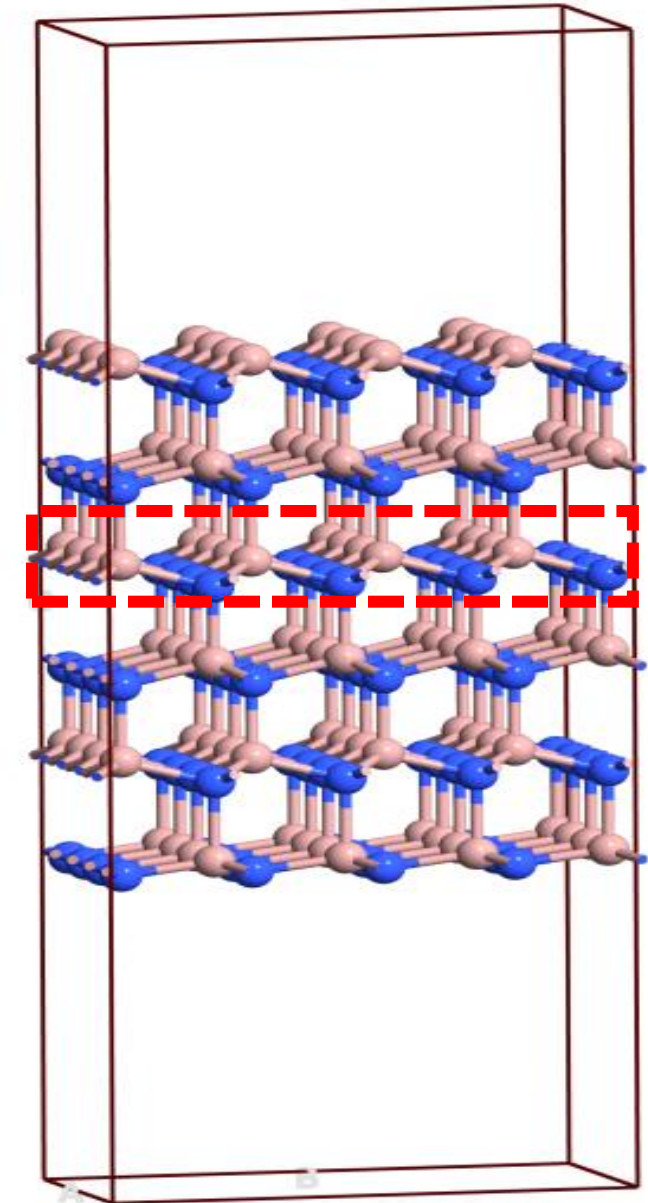
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Zakaria Al Balushi
Nathan Martin
Mel Hainey Jr.

Postdoctoral Scholars

Chen Chen
Jarod Gagnon
Tanushree Choudhury

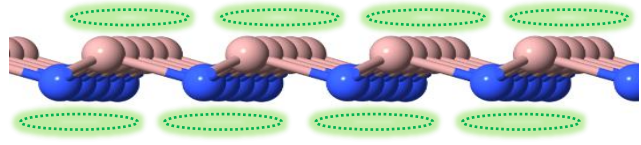
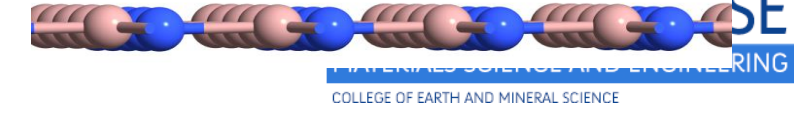




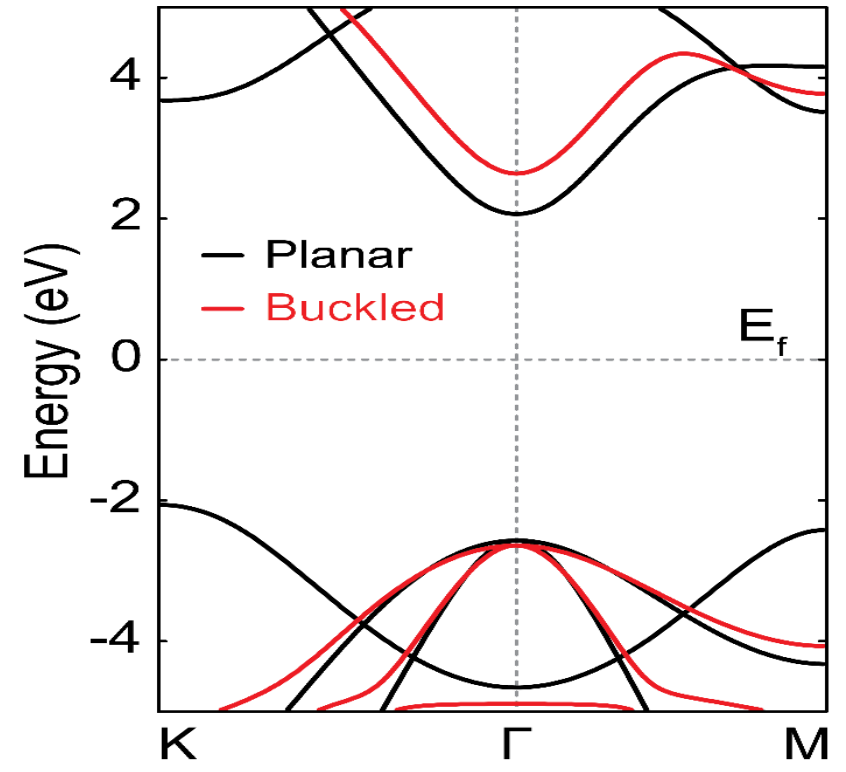


Materials discovery with computation

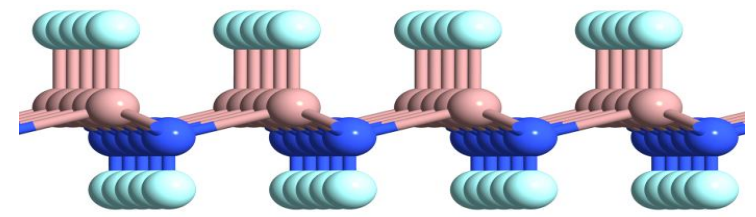
Indirect bandgap 4.12 eV



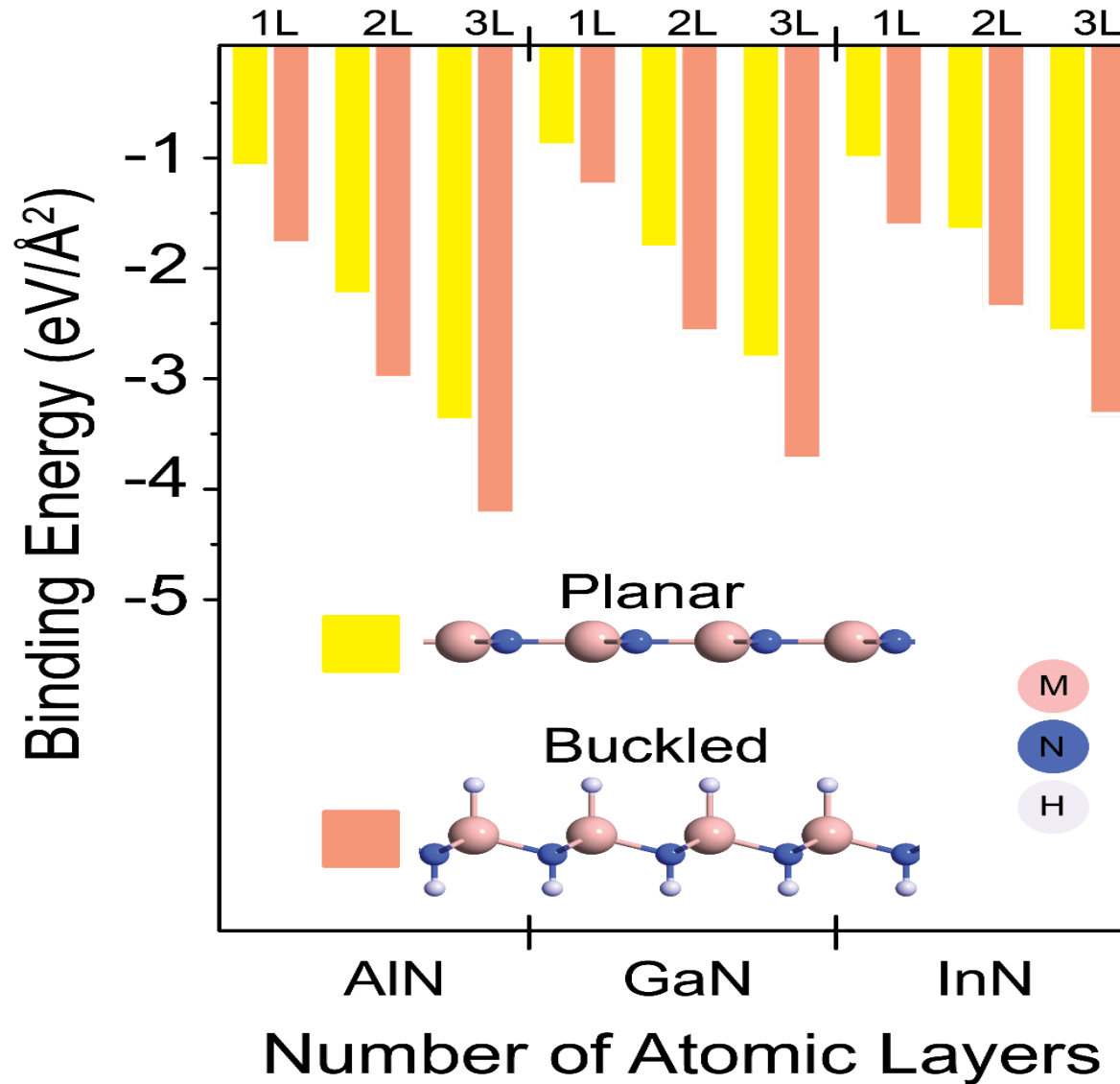
Stabilized Structure

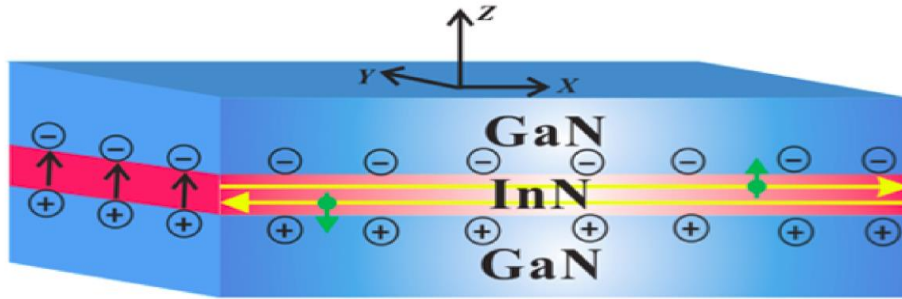


direct bandgap 5.28 eV



The Buckled Structure for 2D III-nitrides is More Stable!





Polarization-induced Topological insulators for memory and quantum computing

Phys. Rev. Lett. **109**, 186803 (2012)

Exotic physics



Single-photon emitters for quantum optics and communication

Nano Lett. **14**, 982–986 (2014)

Nat. Mater. **5**, 887–892 (2006)